

Fig. 1:

(left) Schematic representation of the home-built in situ PL setup.

(right) Evolution of the CdSe/CdS/ZnS core/shell/shell QD PL intensity after repeated exposure to TMA, DEZ, TDMAT and TEMAHf precursor pulses.



Fig. 2:

(left) Embedding of bare QD and polymer encapsulated QD using ALD. (right) Illustration of the in situ monitoring of the QD PL during exposure to ALD-species.



## Fig. 3:

(left) Normalized PL intensity of the CdSe/CdS/ZnS core/shell/shell QD during the entire ALD process. (right) Stability of the PL intensity of the CuInS<sub>2</sub>/ZnS core/shell QD during TiO<sub>2</sub> ALD.